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IBM Docket No. FIS920020157US1

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of: Ricky S. Amos et al.

Serial No.: 10/605,261 Date: January 25, 2006

Filed: September 18, 2003 Group Art Unit: 2812  
Batch No.:

Title: PROCESS OPTIONS OF FORMING  
SILICIDED METAL GATES FOR  
ADVANCED CMOS  
DEVICES

Examiner: Alexander G. Ghyka

**DeLIO & PETERSON, LLC**  
121 Whitney Avenue  
New Haven, CT 06510-1241

**LETTER TO OFFICIAL DRAFTSMAN**

**Mail Stop ISSUE FEE**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Applicants are herewith submitting **16** replacement sheets of Formal Drawings for the approval of the Draftsman.

Please charge the Assignee IBM Corporation Deposit Account No. **09-0458** for any fee related to the acceptance of the attached Formal Drawings. A duplicate copy of this letter is enclosed for that purpose.

Respectfully submitted,

BY:

Attorney: Robert Curcio  
Registration No. 44,638  
(203) 787-0595